| Liectionic rate | nt Application Fe | e mansiin | ··· | | | | |
|---|---------------------|---|--------|-------------------------|--|--|--|
| Application Number: | 10519724 | 10519724 | | | | | |
| Filing Date: | 28-Dec-2004 | 28-Dec-2004 | | | | | |
| Title of Invention: | | Device and method for the production of chlorotriflouride and system for etching semiconductor substrates using said device | | | | | |
| First Named Inventor/Applicant Name: | Franz Laermer | Franz Laermer | | | | | |
| Filer: | Gerard A. Messina/E | Gerard A. Messina/Elizabeth Tretter | | | | | |
| Attorney Docket Number: | 10191/3980 | 10191/3980 | | | | | |
| Filed as Large Entity | <u>'</u> | | | | | | |
| U.S. National Stage under 35 USC 371 Fili | ng Fees | | | | | | |
| Description | Fee Code | Quantity | Amount | Sub-Total in USD(\$) | | | |
| Basic Filing: | ' | | | | | | |
| Pages: | | | | | | | |
| Claims: | | | | | | | |
| Independent claims in excess of 3 | 1614 | 1 | 220 | 220 | | | |
| Miscellaneous-Filing: | | | | | | | |
| Petition: | | | | | | | |
| Patent-Appeals-and-Interference: | | | | | | | |
| Post-Allowance-and-Post-Issuance: | | | | | | | |
| Extension of Time: | | | | | | | |

| Description | Fee Code | Quantity | Amount | Sub-Total in USD(\$) |
|------------------------------------|-------------------|----------|--------|-------------------------|
| Extension - 3 months with \$0 paid | 1253 | 1 | 1110 | 1110 |
| Miscellaneous: | | | | |
| | Total in USD (\$) | | | 1330 |